Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	28	(rapid near thermal near anneal$3 or "RTA") same (alunimum near oxide or "Al.sub.2 O.sub.3")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 19:46
L2	5	(rapid near thermal near anneal$3 or "RTA") same ((alunimum near oxide or "Al.sub.2 O.sub.3") same (remov$3 or stripp$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:03
L3	9762	(alunimum near oxide or "Al.sub.2 O.sub.3") same (remov$3 or stripp$3 or crack$3 or induc$3 or damag$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:23
L4	2465	3 same (anneal$3 or heat$3 or "rta")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:05
L5	2465	3 same (anneal$3 or heat$3 or rapid near thermal? near anneal$3 or "rta")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:05
L6	1798	5 same (clean$3 or remov$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:06
L7	1621	6 and @pd<"20021230"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:08
L8	0	7 and (ferroelectric near random near access near memory or "FeRAM")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:08
L9	61721	(alunimum near oxide or "Al.sub.2 O.sub.3" or alumina) same (etch$3 or remov$3 or stripp$3 or crack$3 or induc$3 or damag$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:25

L10	686	9 and ferroelectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:26
L11	243	9 same (contact near hole)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:29
L12	15522	9 same (thermal$ near treatment or rapid near thermal near anneal$3 or "RTA" or heat$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:30
L13	133	12 and (ferroelectric)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:50
L14	3336	((damag$3 or crack$3) same (etch$3 or stripp$3 or remov$3)) same (alumina or aluminum near oxide or "Al.sub.2 O.sub.3")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:51
L15	14	14 and (contact same barrier near metal)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:52
L16	71241	(crack$3 or damag$3) same insulat$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:58
L17	14419	16 same (etch$3 or remov$3 or stripp$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:59
L18	586	17 same capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 18:59
L19	133	17 same ferroelectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 19:00

L20	54	19 and @pd<"20021230"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 19:16
L21	24	kweon-soon-yong.in.	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:17
L22	2	21 and (crack$3 same adhesion adj layer)	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:20
L23	30	yeom-seung-jin.in.	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:19
L24	1	23 and (crack$3 same adhesion adj layer)	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:20
L25	3181	(irradiat$3 same (clean$3 or etch$3 or stripp$3 or remov$3)) same (alumina or insulat$3)	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:22
L26	215	25 same (crack$3 or damag$3)	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:22
L27	136	26 and @pd<"20021230"	US-PGPUB; USPAT	OR	OFF	2005/08/04 19:22
L28	2074	(rapid near thermal near anneal$3 or "RTA") same (alunimum near oxide or "Al.sub.2 O.sub.3" or alumina or insulat$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 19:47
L29	115	28 same (damag$3 or crack$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/04 19:47